| L Number | Hits | Search Text  | DB                     | Time stamp        |
|----------|------|--|------------------------|-------------------|
| 4        | 83   | "plasma jet" and (pivot\$ or tilt\$) and (rotates or rotated)  | USPAT;                 | 2002/04/02 09:49  |
|          |      |  | US-PGPUB;              |                   |
|          |      |  | EPO; JPO;              |                   |
|          |      |  | DERWENT;               |                   |
|          |      |  | IBM_TDB;<br>USOCR      |                   |
| 5        | 1419 | "plasma jet" and (wafer or substrate or article)   | USPAT;                 | 2002/04/02 09:5   |
|          |      | plantia jet and (water or substrate of article)  | US-PGPUB;              | 2002/04/02 09.3   |
|          |      |  | EPO; JPO;              |                   |
|          |      |  | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
|          |      |  | USOCR                  | 1                 |
| 13       | 182  | ("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$)                            | USPAT;                 | 2002/04/02 10:3   |
|          |      |  | US-PGPUB;              |                   |
|          |      |  | EPO, JPO,              |                   |
|          |      |  | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
|          |      |  | USOCR                  |                   |
| 21       | 147  | ("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or                         | USPAT;                 | 2002/04/02 10:3   |
|          |      | channels or pipes))  | US-PGPUB;              |                   |
|          |      |  | EPO; JPO;              |                   |
|          |      |  | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
| 29       | 108  | (Chalanna intil and Conference whether a still ) and Conference 1 is                                   | USOCR                  | 2002 (04 (02 40 4 |
| . 29     | 100  | (1 ) (0 ) (0 ) (0 ) (0 ) (0 ) (0 ) (0 )  | USPAT;                 | 2002/04/02 10:4   |
|          |      | channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$)) | US-PGPUB;<br>EPO; JPO; |                   |
|          |      | (gas near) injecta))   | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
|          |      |  | USOCR                  |                   |
| 37       | 59   | ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or                       | USPAT;                 | 2002/04/02 11:0   |
| -        |      | channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and                       | US-PGPUB;              | 2002/04/02 11:0:  |
|          |      | (gas near3 inject\$))) and below and above   | EPO; JPO;              | ,                 |
|          |      |  | DERWENT;               | ·                 |
|          |      |  | IBM_TDB;               |                   |
|          |      |  | USOCR                  |                   |
| 45       | 29   | ("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)                            | USPAT;                 | 2002/04/02 12:4   |
|          |      |  | US-PGPUB;              |                   |
|          | ļ    |  | EPO; JPO;              |                   |
|          |      | ·  | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
|          |      |  | USOCR                  |                   |
| 53       | 105  | ("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma                         | USPAT;                 | 2002/04/02 11:1   |
|          |      | jet" and (wafer or substrate or article)) and (levitat\$ or float))                                    | US-PGPUB;              |                   |
|          |      |  | EPO; JPO;              |                   |
|          |      |  | DERWENT;               |                   |
|          |      |  | IBM_TDB;               |                   |
| 61       | 99   | (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma                        | USOCR<br>USPAT;        | 2002/04/02 11:5   |
| 01       | "    | jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((((("plasma                  | US-PGPUB;              | 2002/04/02 11.3   |
|          |      | jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or                      | EPO; JPO;              |                   |
|          |      | pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3                        | DERWENT;               |                   |
|          |      | inject\$))) and below and above) or ((("plasma jet" and (water or substrate or                         | IBM_TDB;               |                   |
|          |      | article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and                      | USOCR                  |                   |
|          |      | (wafer or substrate or article)) and (gas near3 inject\$))))   |                        |                   |
| 69       | 208  | ("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet"                       | USPAT;                 | 2002/04/02 12:0   |
| j        |      | and (wafer or substrate or article)) and (levitat\$ or float))   | US-PGPUB;              | •                 |
| 1        |      | · · · · · · · · · · · · · · · · · · ·  | EPO; JPO;              |                   |
| 1        |      |  | DERWENT;               |                   |
| 1        |      |  | IBM_TDB;               |                   |
| ļ        |      |  | USOCR                  |                   |

| 70 | 164 | (("placema jet" and (water or substants or article)) and mic\$ not (("placema jet"   | USPAT;   | 2002/04/02 12:01             |
|----|-----|--|--|------------------------------|
| ļ  |     | (("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet"   | US-PGPUB;  | 2002/04/02 12:01             |
| 1  |     | and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer   | EPO; JPO;  |                              |
| 1  |     |  | DERWENT;   |                              |
|    |     | or substrate or article)) and (levitat\$ or float))) not ((((("plasma jet" and (wafer  |  |                              |
| ļ  |     | or substrate or article)) and (gas near3 (conduits or channels or pipes))) not   | IBM_TDB;   |                              |
| 1  |     | (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and   | USOCR  |                              |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and   |  |                              |
|    |     | (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or  |  | 1                            |
|    |     | substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or  |  |                              |
|    |     | substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate  |  |                              |
|    |     | or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or   |  |                              |
|    |     | article)) and (levitat\$ or float)) or (((("plasma jet" and (wafer or substrate or   |  |                              |
| i  | •   | article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and  |  |                              |
|    |     |  |  |                              |
| 70 | 101 | (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))  | 1100.47  | 0000/04/004004               |
| 78 | 101 | ((("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet"   | USPAT;   | 2002/04/02 12:01             |
|    |     | and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet"   | US-PGPUB;  |                              |
|    |     | and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer   | EPO; JPO;  |                              |
|    |     | or substrate or article)) and (levitat\$ or float))) not ((((("plasma jet" and (wafer  | DERWENT;   |                              |
| l  |     | or substrate or article)) and (gas near3 (conduits or channels or pipes))) not   | IBM_TDB;   |                              |
|    |     | (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and   | USOCR  |                              |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and   |  |                              |
|    |     | (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or  |  |                              |
| į  |     |  |  |                              |
| ļ  | •   | substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or  |  |                              |
|    |     | substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate  |  |                              |
|    |     | or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or   |  |                              |
| -  |     | article)) and (levitat\$ or float)) or (((("plasma jet" and (wafer or substrate or   |  |                              |
| į  |     | article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and  |  | }                            |
|    |     | (wafer or substrate or article)) and (gas near3 inject\$))) and below and above)))   |  |                              |
|    |     | and below  |  |                              |
| 86 | 101 |  | USPAT;   | 2002/04/02 12:01             |
|    | 101 | and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet"   | US-PGPUB;  |                              |
| 1  |     |  |  |                              |
|    |     | and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer   | EPO; JPO;  |                              |
|    |     | or substrate or article)) and (levitat\$ or float))) not ((((("plasma jet" and (wafer  | DERWENT;   |                              |
| 1  |     | or substrate or article)) and (gas near3 (conduits or channels or pipes))) not   | IBM_TDB;   | •                            |
| i  |     | (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and   | LICOCD   |                              |
| ļ  |     |  | USOCR  |                              |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and   | USOCK  |                              |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and   | USOCK  | _                            |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or   | USOCK  | •                            |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or   | USOCK  |                              |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate   | USOCK  | •                            |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or  |  | •                            |
|    | 11  | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or  | USOCK  | •                            |
|    | 11  | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and  |  | •                            |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above)))   | <i>J</i> SOCK  | •                            |
|    |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath)   | ,  | •                            |
| 94 |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above)))   | USPAT;   | 2002/04/02 12:49             |
| 94 |     | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and (((("plasma jet" and  | ,  | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and ((("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet" and (wafer or  | USPAT;<br>US-PGPUB;                                      | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and ((("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)))  | USPAT;<br>US-PGPUB;<br>EPO; JPO;                         | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and ((("plasma jet" and (wafer or substrate or article)) and rais\$ not (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;             | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and ((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (((("plasma jet" and (wafer or substrate or article)) and (((("plasma jet" and (wafer or substrate or article)) and ((((("plasma jet" and (wafer or substrate or article)) and (((((((((((((  | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB; | <b>-</b><br>2002/04/02 12:49 |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet"   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;             | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not (((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (wafer or            | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB; | 2002/04/02 12:49             |
| 94 | 8   | below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$)))) or (("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) or (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float)) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above))) and (below or underneath) (c23c016\$.ipc. or c23c014\$.ipc. or h01l021\$.ipc) and (((("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and suspend\$ not (("plasma jet" and (wafer or substrate or article)) and (levitat\$ or float))) not ((("plasma jet" and (wafer or substrate or article)) and (gas near3 (conduits or channels or pipes))) not (("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and below and above) or ((("plasma jet" and (wafer or substrate or article)) and (gas near3 inject\$))) and (gas near3   | USPAT;<br>US-PGPUB;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB; | 2002/04/02 12:49             |
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